

INFORMATION DISCLOSURE CITATION (USE SEVERAL SHEETS IF NECESSARY)					Complete if Known			
					Application Number		10/553,573	
					Filing Date		October 17, 2005	
					First Named Inventor		Christian DUSSARRAT	
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					Examiner Name			
					Elizabeth A. Burkhart			
Sheet	1	of	1	Attorney Docket Number	Serie 6070			
U.S. PATENT DOCUMENTS								
Examiner Initials	Cite No.	Document Number	Publication Date	Name	Pages Column, Lines Where Relevant Passages or Relevant Figures Appear			
	A1	US 5 932 286	8/03/1999	BEINGLASS et al.				
FOREIGN PATENT DOCUMENTS								
Examiner Initials	Cite No.	Document Number	Publication Date	Name	Pages Column, Lines Where Relevant Passages or Relevant Figures Appear			
NON PATENT LITERATURE DOCUMENTS								
Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published				T		
	C1	PEREIRA, M.A. et al., "Silicon nitride deposited by ECR-CVD at room temperature for LOCOS isolation technology," Applied Surface Science 212-213 (2003), pp. 388-392						
	C2	YOTA, J. et al., "A comparative study on inductively-coupled plasma high-density plasma, plasma-enhanced, and low pressure chemical vapor deposition silicon nitride films," J. Vac. Sci. Technol. A 18(2), Mar/Apr 2000, pp. 372-376						
Examiner			Date Considered					
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